

**Electrodeposited nickel-sulfide films as competent hydrogen evolution catalysts in neutral water**

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ARTICLE

Electrodeposited nickel-sulfide films as competent hydrogen evolution catalysts in neutral water

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The development of low-cost, efficient, and robust electrocatalysts of the hydrogen evolution reaction (HER) is a crucial step toward the conversion and storage of sustainable and carbon-neutral energy resources, such as solar energy. Not only the HER catalysts need to be composed of inexpensive elements, they are also desirable to be prepared at low energy cost. In this work, we report that nickel-sulfide (Ni-S) films prepared by facile potentiodynamic deposition are active HER catalysts in aqueous media. Notably, the Ni-S films showed catalytic activity in water with a wide range of pH values (0 to 14), as well as in natural water. In pH 7 phosphate buffer, a current density of 60 mA/cm² could be achieved with a Tafel slope of 77 mV/dec and a Faradaic efficiency of 100%. A long-term bulk electrolysis of the Ni-S film exhibited steady current over 100 h with no deactivation, demonstrating its superior stability in neutral water. Further, an initial activation process was observed, which is likely due to increase in the effective surface area of the Ni-S film under electrocatalytic conditions. A suite of characterization techniques, including X-ray photoelectron spectroscopy and X-ray absorption spectroscopy, were conducted to probe the composition and structure of the Ni-S film, revealing that its major component is Ni₃S₂ which was preserved under electrocatalytic conditions.

Introduction

The growing global energy demands, depletion of fossil fuel reserves, as well as increasing concerns about climate change resulting from fossil fuel combustion have urged the exploration of green and sustainable energy resources. Solar energy is a promising candidate owing to its gigantic capacity.¹ However, its diurnal and intermittent nature requires efficient capture and storage. In this respect, solar-driven water splitting to produce hydrogen and oxygen is an attractive means to store solar energy in chemical forms.² Hydrogen, when generated from water with renewable energy input, is an ideal energy carrier with minimal climate impact since water is the sole product of its combustion.² In addition, hydrogen is also an important chemical feedstock, playing a crucial role in petroleum refining and NH₃ synthesis for fertilizer.³ Thus, significant efforts have been devoted to developing efficient catalysts for the hydrogen evolution reaction (HER).

Solid-state catalysts employing noble metals, such as platinum, have long been recognized as competent HER catalysts with low overpotential and great stability,⁴ however the associated scarce and high cost limit their application on a large scale. It remains a great challenge to develop inexpensive HER catalysts exhibiting both high efficiency and strong robustness in aqueous media, preferably neutral water.⁵ Recent years have witnessed the emergence of several promising solid-state HER catalysts composed of earth-abundant elements. For example, molybdenum sulfides of varying morphologies have

been reported to be active HER catalysts in strong acidic solution.^{6–10} MoB,^{11,12} Mo₂C,^{13,14} metal-doped molybdenum sulfides M-MoS₂ (M = Fe, Co, Ni, etc),¹⁵ and Cu₂MoS₄¹⁶ were also published recently showing good to excellent HER catalysis in acidic media. In addition, heterogeneous HER catalysts of first-row transition metals were also reported, such as H₂-CoCat,¹⁷ MS₂ (M = Fe, Co, Ni),¹⁸ CoP,^{19,20} CoSe₂,²¹ Co-NRCNT,²² FeS,²³ FeP,²⁴ and Ni₂P.²⁵ These catalysts are usually studied in strong acidic electrolyte and some of them require toxic gas treatment at elevated temperature.

In order to minimize environmental impact and increase biocompatibility, it is very desirable to conduct hydrogen evolution in neutral water, which is the ultimate ideal solvent for water splitting. We recently reported that potentiodynamic deposition was able to produce cobalt-sulfide films as HER catalysts in neutral phosphate buffer.²⁶ Herein, we describe that a slightly modified method enabled us to generate amorphous nickel-sulfide (Ni-S) films as well. Electrochemical experiments under various conditions demonstrate that the Ni-S films are very active HER catalysts in water over a wide range of pH values. The Ni-S film maintained its catalytic activity over 100 h in pH 7 phosphate buffer with a Tafel slope of 77 mV/dec and a Faradaic efficiency of 100%. X-ray photoelectron spectroscopy and X-ray absorption spectroscopy results revealed that the major composition of the Ni-S film is Ni₃S₂, distinctive from the HER catalyst of NiS₂ reported recently.¹⁸ To the best of our knowledge, this is the first time that amorphous Ni-S films prepared by potentiodynamic

deposition are reported to exhibit efficient and robust hydrogen evolution catalysis in aqueous media, ranging from strong acidic to strong basic, as well as natural water.

Results and discussion

In a typical preparation of the Ni-S film, two thoroughly cleaned fluorine-doped tin oxide (FTO) electrodes were used as the working and counter electrodes, respectively, with a Ag/AgCl electrode as the reference electrode. The potentiodynamic deposition was conducted with deoxygenated 5 mM NiSO₄ and 0.5 M thiourea in water. Linear voltammetry scans in the range of -1.2 to 0.2 V vs Ag/AgCl were conducted at a scan rate of 5 mV/s for a certain number of cycles (Figure S1). The cathodic scans of four samples prepared by 5, 10, 15, and 20 cycles, respectively, are compared in Figure S2, where the one of 15 cycles exhibits the best activity. Hence, the following experiments were conducted on Ni-S samples prepared with 15 cycles. Along the deposition process, the area of the FTO working electrode exposed to the electrolyte solution gradually turned black and a uniform film formed on the surface. At the end of deposition, the working electrode was rinsed with water gently and dried under vacuum at room temperature overnight, followed by annealing under nitrogen at 300°C for 4 h, which was found to strengthen the mechanic stability of the deposited film attached to FTO. The scanning electron microscopy (SEM) image of a typical Ni-S/FTO electrode is displayed in Figure 1a, showing nearly complete coverage of the Ni-S film on FTO. No regular crystalline particles or aggregates were observed. Cross section SEM images of the deposited film indicate that the film thickness is around 700 nm (Figure S3). The presence of nickel and sulphur in the deposited film was confirmed by energy dispersive X-ray spectroscopy (EDS) in Figure S4. The signals of Sn, O, Si, and F are attributed to the FTO-coated glass substrate. Powder X-ray diffraction (XRD) pattern of Ni-S/FTO is compared to that of a blank FTO in Figure S5. All the XRD peaks are due to the presence of FTO, whereas no unique diffraction was noticed for the Ni-S film. Hence, it's concluded that the Ni-S film is amorphous in nature. Elemental analysis via inductively coupled plasma optical emission spectrometry (ICP-OES) for four Ni-S/FTO samples prepared with different surface area indicates that the average mass loading of Ni is 81.50 μg/cm² and the Ni/S ratio is close to 1.55 (Table S1).

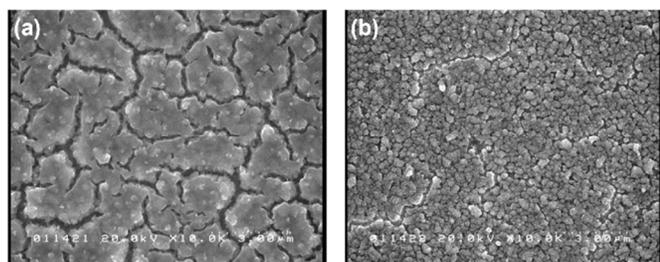


Figure 1. SEM images of Ni-S/FTO before (a) and after (b) a 1-h electrolysis in pH 7 phosphate buffer at -0.689 V vs SHE. The post-electrolysis Ni-S film displays a rougher and more porous surface compared to the pre-electrolysis one.

The HER catalysis of the Ni-S film was first evaluated in neutral water. Figure 2a shows the polarization curve of Ni-S/FTO in pH 7 phosphate buffer at a scan rate of 5 mV/s. The polarization curve of a blank FTO electrode is also included as

a comparison. It is apparent that the blank FTO did not show any HER catalytic activity until -0.95 V vs SHE, however a catalytic current was observed for Ni-S/FTO beyond -0.55 V vs SHE (Figure 2b). Further scanning towards negative potential produced a dramatic increase in current density, accompanied with vigorous growth and release of hydrogen bubbles from the electrode surface. To reach current densities of 1 and 10 mA/cm², the Ni-S/FTO electrode required overpotentials of 227 and 330 mV, respectively. These values compare favorably with other solid-state earth-abundant HER catalysts at pH 7 (Table S2). Notably, the linear fitting of the Tafel plot (Figure 2c) rendered a Tafel slope of 77 mV/dec, which is among the smallest Tafel slopes obtained for non-noble metal HER catalysts in neutral water. For instance, the MoS₂ film showed a Tafel slope of 86 mV/dec at pH 7, and the first-row transition metal doping in MoS₂ did not decrease the Tafel slope (87-96 mV/dec).¹⁵ Electrodeposited nickel hydroxide/oxide film was reported to be active for hydrogen evolution catalysis, however it required an overpotential of 452 mV to reach 1.5 mA/cm² with a much larger Tafel slope (226 mV/dec) in a borate buffer (pH 9.2).²⁷ Although the Co-S film prepared in a similar manner exhibited a better onset overpotential than the Ni-S film, the former possessed a larger Tafel slope (93 mV/dec).²⁶ Another elegant Janus cobalt catalyst prepared by electrodeposition showed a Tafel slope of 140 mV/dec and required an overpotential of ~325 mV to reach 1 mA/cm².¹⁷ NiS₂¹⁸ and Ni₂P²⁵ nanoparticles were recently reported showing HER catalytic activity, however they were studied in strong acidic media and no data in neutral water was available.

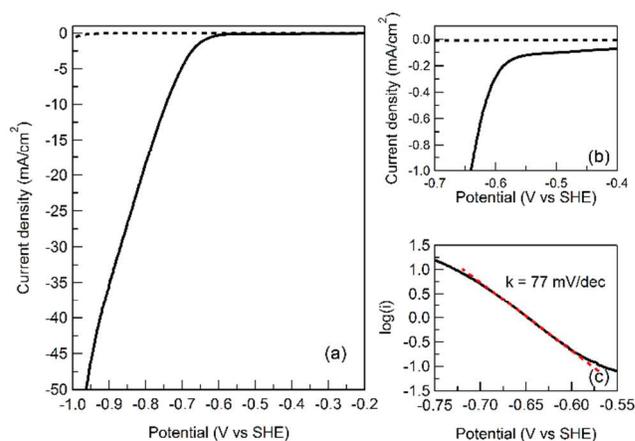


Figure 2. (a, b) Polarizations of Ni-S/FTO (solid) and blank FTO (dotted) in pH 7 phosphate buffer (scan rate: 5 mV/s), and (c) the Tafel plot of Ni-S/FTO (black solid) with its linear fitting (red dotted) in the region of -0.55 to -0.65 V vs SHE.

It was reported that three principal steps are involved in the hydrogen evolution reaction: Volmer (discharge), Tafel (recombination), and Heyrovsky (desorption) steps.²⁸ Depending on which one is the limiting step, the Tafel slope could be 29, 38, or 116 mV/dec, respectively. The deviation of the 77 mV/dec slope of the Ni-S film from those three principal values indicates the complexity of the hydrogen evolution mechanism of this system. The detailed mechanistic understanding is under current investigation.

We next investigated the Faradaic efficiency of the Ni-S film in HER catalysis through a chronopotentiometry experiment maintaining a catalytic current of 2 mA for 2.5 h.

As shown in Figure S6, the increasing amount of generated hydrogen was measured by gas chromatography and compared with the theoretical amount assuming all the passed charges were used to produce hydrogen. The close match of the measured and calculated hydrogen volume demonstrates a 100% Faradaic efficiency of Ni-S/FTO in HER electrocatalysis. Given the average loading mass of Ni ($81.5 \mu\text{g}/\text{cm}^2$, Table S1), the mole of Ni ($0.534 \mu\text{mol}$) in the Ni-S film is only $\sim 0.5\%$ of the mole of hydrogen (0.1 mmol) produced during the 2.5-h electrolysis.

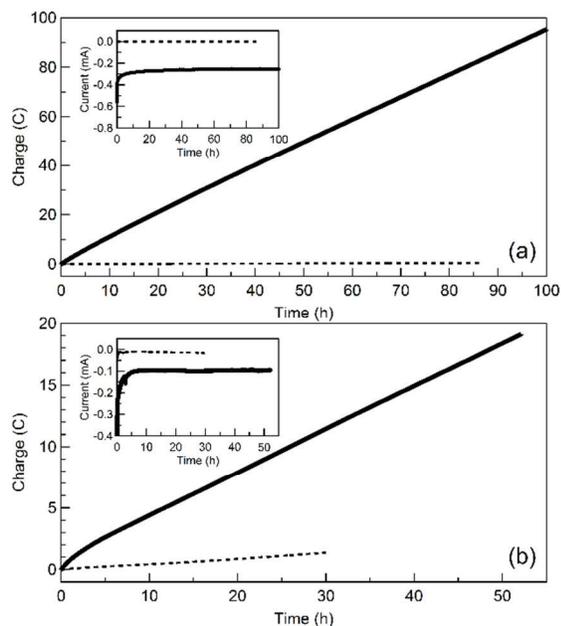


Figure 3. Long-term controlled potential electrolysis of Ni-S/FTO (solid line) in (a) 1.0 M phosphate buffer of pH 7 at -0.700 V vs SHE and (b) filtered Great Salt Lake water at -0.959 V vs SHE. The insets in (a) and (b) plot the corresponding current change over time during the electrolysis experiments. The dashed lines in (a) and (b) represent the controlled potential electrolysis experiments of blank FTO electrodes conducted under the same conditions.

In order to assess the long-term stability of the Ni-S film for HER catalysis, an extended electrolysis was carried out. Figure 3a presents the accumulated charge of Ni-S/FTO in pH 7 phosphate buffer at -0.700 V vs SHE for 100 h. A nearly linear charge accumulation over time clearly demonstrates the robust durability of the Ni-S film for HER electrocatalysis, which is corroborated by the steady current over the entire course (Figure 3a inset). It should be noted that a blank FTO electrode only generated negligible charge build-up under the same condition. Calculations from the average loading mass of Ni (Table S1) and passed charge during the 100-h electrolysis resulted in a turnover number of 925 mole H_2 per mole Ni. It should be noted that this value only represents an underestimated activity of the Ni-S film, since catalysis is expected to occur at the active sites on the surface and the film has a thickness of $\sim 650 \text{ nm}$ (Figure S3). From the very stable catalytic current over the entire electrolysis, it is highly anticipated that the Ni-S film will maintain its catalytic activity for a much longer duration than 100 h.

Such a remarkable robustness of the Ni-S film prompted us to explore its catalytic performance under extreme conditions. Since the majority of solid-state HER catalysts reported recently were studied in strong acidic media, we first

investigated the HER catalysis of Ni-S/FTO in $0.5 \text{ M H}_2\text{SO}_4$. As shown in Figure S7, Ni-S/FTO was able to reach catalytic current densities of 1, 10, 20 mA/cm^2 at overpotentials of 150, 213, and 243 mV, respectively. A linear fitting of its Tafel plot resulted in a Tafel slope of 52 mV/dec (Figure S7 inset). These overpotentials and Tafel slope compare favorably to the values reported for other earth-abundant HER catalysts (Table S3). An electrolysis of Ni-S/FTO at -0.168 V vs SHE was conducted for 90 min (Figure S8). The catalytic current decreased during the first half hour, followed by stabilization during the following hour. The initial decrease was likely due to the dissolution and/or detachment of the catalyst film from the FTO electrode. Nevertheless, the intrinsic electrocatalytic activity of Ni-S/FTO suggests that it is among the most active HER electrocatalysts in strong acidic media (Table S3).

We next assessed the HER catalytic performance of the Ni-S film in 1.0 M KOH . A catalytic current density of $20 \text{ mA}/\text{cm}^2$ was achieved at -1.05 V vs SHE with a Tafel slope of 88 mV/dec (Figure S9). A 7-h electrolysis of Ni-S/FTO at -1.05 V vs SHE afforded an essentially linear charge build-up with no current decrease during the entire period (Figure S10). It demonstrates the great stability of Ni-S/FTO in strong basic media.

Given the low cost and wide availability, natural water is an ideal substrate for water splitting. A natural water sample collected from the Great Salt Lake was filtered through a medium frit to remove insoluble particles and directly used as an electrolyte solution. As depicted in Figure 3b, a long-term electrolysis of the Ni-S film was conducted in the Great Salt Lake water at -0.959 V vs SHE over 50 h. Despite an initial current decrease during the first few hours, the catalytic current stabilized and persisted for the rest period (Figure 3b inset). Hydrogen formation was confirmed by gas chromatography. A 30-h electrolysis of a blank FTO electrode did not generate an appreciable amount of hydrogen under the same condition, implying that the species in the Great Salt Lake water were not able to form *in situ* HER catalysts that can compete with the Ni-S film. Overall, these results demonstrate that the Ni-S film is a competent and robust HER catalyst even in natural water.

During the electrocatalytic studies of the Ni-S film, an activation process was observed. As shown in Figure S11, consecutive cathodic scans led to an increase in catalytic current and a stabilized current density was achieved after roughly 9 to 10 scans. To investigate the catalyst properties before and after electrochemical experiments, a controlled potential electrolysis of a fresh-prepared Ni-S/FTO was conducted at -0.689 V vs SHE for 1 h (Figure S12). Electric impedance spectra of the Ni-S film before and after the 1-h electrolysis were compared in Figure S13. The Nyquist plots (Figure S13b) indicate that there was no substantial resistance change of the catalyst film, showing a slight increase from 100 to 110 Ω . Therefore, resistance change can be ruled out as a cause of the enhanced activity.

It has been reported that cyclic voltammetry at non-Faradaic potentials is able to probe the electrochemical double layer as a means for estimating the effective electrode surface area.²⁹ By plotting the difference in current density between the anodic and cathodic scans ($\Delta j = j_a - j_c$) at a certain overpotential against the scan rate, a linear relationship could be obtained. Fitting this data to a straight line enables the extraction of the geometric double layer capacitance (C_{dl}), which is known to be proportional to the effective electrode surface area. The extracted slopes of those fitting lines allow a comparison of the relative surface areas of electrodes with different morphologies,

especially when these electrodes consist of the same material. Figures 4a and 4b present the cyclic voltammograms of a Ni-S/FTO electrode before and after the 1-h electrolysis (Figure S9) in the non-Faradaic region of -0.26 — -0.16 V vs SHE. As the scan rate varied from 20 to 220 mV/s, the cathodic and anodic current densities increased accordingly. Depicted in Figure 4c are the plots of Δj vs scan rate. The calculated capacitance of the post-electrolysis Ni-S film is 455.7 μF , nearly 34 times that before electrolysis (13.5 μF), which indicates the effective surface area of the post-electrolysis film is nearly 34 times that of the pre-electrolysis sample. This result is consistent with the rougher and more porous surface of the Ni-S film after electrolysis (Figure 1b) compared to a fresh Ni-S film (Figure 1a). A larger surface area is able to provide more active sites for the hydrogen evolution reaction, leading to increased catalytic current density.^{15,21} Therefore, the observed activation process is probably due to the enhanced specific surface area resulting from surface reorganization under electrochemical conditions.

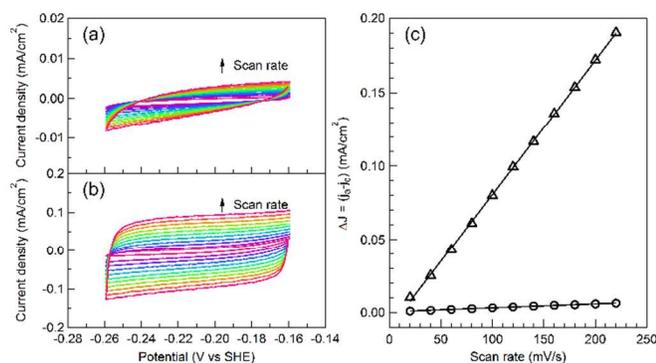


Figure 4. Cyclic voltammograms of Ni-S/FTO in the non-Faradaic region before (a) and after (b) a 1-h electrolysis at -0.689 V vs SHE in pH 7 phosphate buffer, and (c) scan rate dependence of the current densities of the pre- and post-electrolysis Ni-S films at -0.21 V vs SHE.

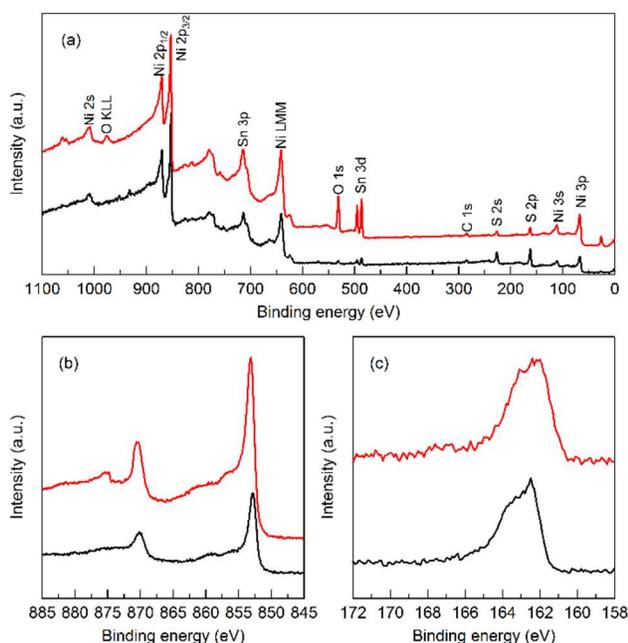


Figure 5. XPS spectra of the Ni-S films before (black) and after (red) a 1-h electrolysis at -0.689 V vs SHE in pH 7 phosphate buffer: (a) survey, (b) Ni 2p region, and (c) S 2p region.

To further probe the surface composition of the Ni-S film, X-ray photoelectron spectroscopy (XPS) was conducted (Figure 5). Figure 5a includes the XPS survey spectra of the Ni-S films before and after the same 1-h electrolysis. Before electrolysis, all the observed peaks can be assigned to anticipated elements, including Ni and S, in Ni-S/FTO. The Sn 3d and 3p peaks are attributed to the FTO substrate. It's worth noting that no Pt and/or Ag peaks were detected, indicating that Ni-S/FTO is free of noble metal impurities. The high-resolution region of Ni 2p spectra (Figure 5b) shows peaks at 853.1 and 870.3 eV, corresponding to Ni 2p_{3/2} and 2p_{1/2}, respectively.³⁰ The shoulder around 855-860 eV implies the presence of Ni(OH)₂ and NiSO₄.³⁰ XPS fitting of the Ni 2p_{3/2} peak of the pre- and post-electrolysis samples resulted in similar binding energies (Figure S14). For instance, the fitted peak at 853.04 eV of the post-electrolysis sample is similar to those reported for Ni₃S₂,³¹ NiS,³² and NiS₂.³³ The similarity in the binding energy of Ni 2p_{3/2} peak of different nickel sulfides is known.³⁰ The process giving rise to the Ni 2p_{3/2} peak is mainly of metal (Ni) character, with little contribution from the surrounding ligand. This also explains why it is close to that of Ni metal (852.5±0.2 eV).³⁰ Therefore, we cannot solely rely on the binding energy of the Ni 2p_{3/2} peak to determine the identity of nickel sulfide in the Ni-S film. Whereas, the simulated peaks at 854.73 and 857.00 eV can be assigned to Ni(OH)₂ and NiSO₄, respectively.³⁰ Spectral fitting of the high resolution region of the S 2p signal (Figure S15) resulted in a doublet of 162.31 and 163.51 eV (161.82 and 163.00 eV for the pre-electrolysis sample), corresponding to S 2p_{1/2} and 2p_{3/2}, respectively.

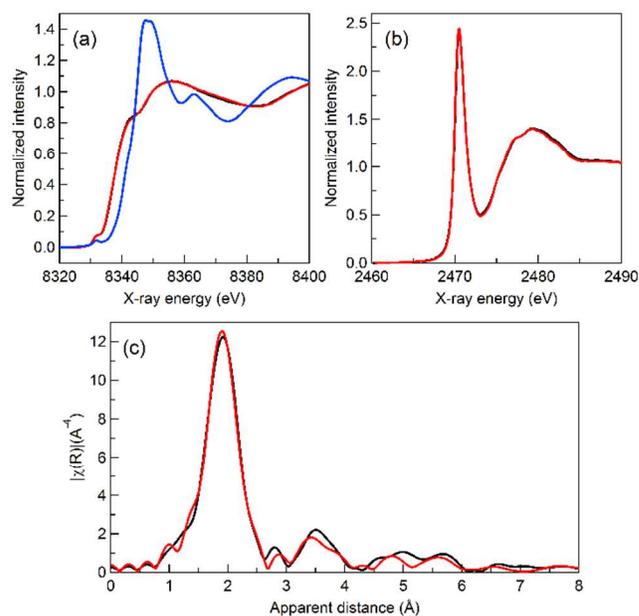


Figure 6. Ni K-edge (a) and S K-edge (b) XANES spectra and Ni EXAFS spectra (c) of the Ni-S films before (black) and after (red) a 1-h electrolysis at -0.689 V vs SHE in pH 7 phosphate buffer. Blue curve in (a) is the Ni K-edge XANES spectrum of Ni(OH)₂ as a comparison.

In order to gain more insights into the atomic structure of the bulk Ni-S film, X-ray absorption spectroscopy was carried out. The Ni K-edge X-ray absorption near edge structure (XANES)

and extended X-ray absorption fine structure (EXAFS) spectra of a Ni-S film before and after the 1-h electrolysis are shown in Figures 6a and 6c, respectively. The XANES spectrum of the post-electrolysis sample is almost identical to that of the pre-electrolysis counterpart, which confirms that the bulk catalyst film experienced little structural change during the electrolysis, while the surface morphology changed and the film became more porous as shown in Figure 1. The Ni K-edge XANES spectrum of Ni(OH)₂ was also included in Figure 6a (blue trace) as a comparison. The drastic difference in spectral shape and energy of the Ni-S film and Ni(OH)₂ unambiguously rules out the latter as a major component of the film. In addition, compared with the reported XANES spectra of Ni,³⁴ NiO,³⁴ NiS,^{35,36} and NiS₂,³⁵ the appreciable involvement of these species in the Ni-S film can also be excluded. In fact, the Ni K-edge XANES spectrum of the Ni-S film resembles that of Ni₃S₂ very well, which is further supported by the Ni EXAFS spectra (Figure 6b).^{34,35} Ni₃S₂ (heazlewoodite) is one of the stable forms of nickel sulfides.³⁷ Each nickel atom in crystalline Ni₃S₂ occupies a pseudotetrahedral site in an approximately body-centered cubic sulfur lattice.³⁸ The Ni₃S₂ units are interconnected through short Ni-S and Ni-Ni distances, 2.2914(5) and 2.5319(9) Å, respectively, within the Ni₃S₂ unit. However, the Ni-S and Ni-Ni distances are even shorter between Ni₃S₂ units, being 2.2534(5) and 2.4966(4) Å, respectively. Figure 7 displays the crystal structure of Ni₃S₂ and highlights its trigonal bipyramidal core. Ni EXAFS linear combination fitting of the post-electrolysis Ni-S film (Table S4) suggests that its major component is Ni₃S₂ with a small contribution of Ni(OH)₂ (8%). The bond distances of Ni-S (2.27(0.04) Å) and Ni-Ni (2.51(0.04) Å) resulting from the EXAFS fitting well match those in the crystal structure of Ni₃S₂. The short Ni-Ni distances in Ni₃S₂ have been proposed to be indicative of metal-metal bonding.³⁷ Indeed, the fitted Ni-Ni distance in the Ni-S film (2.51 Å) is very close to that in metallic nickel (2.49 Å).^{38a} This result is also consistent with the close binding energy of Ni 2p_{3/2} peak of the Ni-S film (Figure 5b) and Ni metal.³⁰ Overall, combination of the XPS and XAS results, together with the ICP-OES data, unambiguously demonstrate that Ni₃S₂ is the major composition of the Ni-S film.

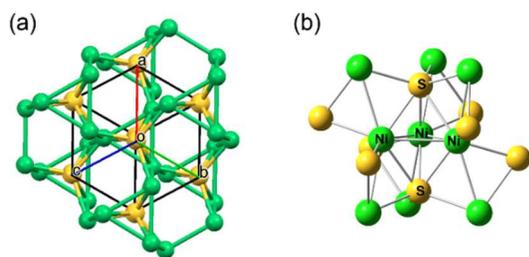


Figure 7. (a) Crystal structure of Ni₃S₂ viewed through the body diagonal direction; (b) selected region of the Ni₃S₂ structure highlighting its trigonal bipyramidal core (green: nickel; yellow: sulfur).³⁸

Conclusions

In summary, we have demonstrated that amorphous Ni-S films prepared by facile potentiodynamic deposition are efficient, robust, and inexpensive HER catalysts in a variety of aqueous media, ranging from strong acidic, neutral, strong basic, to natural water. The catalyst possesses a Tafel slope of 77 mV/dec, a Faradaic efficiency of 100%, and superior stability for at least 100 h at pH 7. An initial activation process was observed, which is likely due to the increased surface area of the Ni-S film resulting from surface reorganization under electrocatalytic conditions. Finally, surface and structural characterizations via SEM, EDS, ICP-OES, XRD, XPS, and XAS conclude the amorphous nature of the Ni-S film with a major composition of Ni₃S₂, which was preserved during the electrochemical experiments. The detailed structural/activity investigation of the Ni-S film for hydrogen evolution requires *in situ* detection of the surface active sites under electrochemical conditions and is currently underway.

Experimental section

Materials

Nickel sulfate, thiourea, potassium hydroxide, potassium chloride, monobasic dihydrogen phosphate, dibasic monohydrogen phosphate, and sulfuric acid, were all purchased from commercial vendors and used as received. Water was deionized (18 Ω) with a Barnstead E-Pure system.

Electrochemical methods

Electrochemical experiments were performed on Gamry Interface 1000 potentiostats. FTO electrodes (8 Ω/cm) were purchased from Hartford Glass and cut into a size of *ca.* 1 cm × 5 cm for electrochemical experiments. Aqueous Ag/AgCl reference electrodes (saturated KCl) were purchased from CH Instruments. The reference electrode in aqueous media was calibrated with ferrocenecarboxylic acid whose Fe^{3+/2+} couple is 0.284 V vs SCE.³⁹ All potentials reported in this paper were converted from vs SCE to vs SHE by adding a value of 0.241 V. iR (current times internal resistance) compensation was applied in polarization and controlled potential electrolysis experiments to account for the voltage drop between the reference and working electrodes using the Gamry Framework™ Data Acquisition Software 6.11. Electric impedance spectroscopy measurements were carried out in the same configuration at -0.689 V vs SHE from 10⁻⁵-0.1 Hz with an AC potential amplitude of 30 mV.

Preparation of Ni-S/FTO electrodes

Prior to electrodeposition, FTO electrodes were sonicated in acetone, water, and ethanol, consecutively. Each sonication was conducted for at least 15 min. Subsequently, the FTO electrodes were rinsed with ethanol, dried, and stored under vacuum at room temperature. Scotch tape was used to cover the working FTO electrode with only a circular area of diameter = 7 mm exposed to the deposition solution (5 mM NiSO₄ and 0.5 M thiourea in water). Another blank FTO was used as the counter electrode with a Ag/AgCl electrode as the reference electrode. Nitrogen was bubbled through the electrolyte solution for at least 20 min before deposition and maintained during the entire deposition process. The potential of consecutive linear scans was cycled between -1.2 and 0.2 V vs Ag/AgCl at a scan rate of 5 mV/s under stirring. Figure S1 shows a typical cyclic voltammograms of the deposition of a Ni-S film on FTO. After deposition, the Ni-S/FTO electrode was removed from the deposition bath and rinsed with copious water gently. The Ni-S/FTO was dried under vacuum at room

temperature overnight, followed by annealing at 300 °C for 4 h under nitrogen. The prepared Ni-S/FTO electrodes were always stored under vacuum at room temperature prior to electrochemical experiments.

Physical methods

The generated hydrogen volume during electrolysis was quantified with a SRI gas chromatography system 8610C equipped with a Molecular Sieve 13× packed column, a HayesSep D packed column, and a thermal conductivity detector. The oven temperature was maintained at 60 °C and argon was used as the carrier gas. Scanning electron microscopy images were collected from a Hitachi S4000 scanning electron microscope. X-ray diffractions were recorded on a Rigaku MiniflexII Desktop X-ray diffractometer. Nitrogen and sulfur analysis were obtained on a Thermo Electron iCAP inductively coupled plasma spectrophotometer.

X-ray photoelectron spectroscopy analyses were done using a Kratos Axis Ultra instrument (Chestnut Ridge, NY) at Surface Analysis Laboratory, University of Utah Nanofab. The samples were affixed on a stainless steel Kratos sample bar, loaded into the instrument's load lock chamber, and evacuated to 5×10^{-8} torr before it was transferred into the sample analysis chamber under ultrahigh vacuum conditions ($\sim 10^{-10}$ torr). X-ray photoelectron spectra were taken using the monochromatic Al K α source (1486.7 eV) at a $300 \times 700 \mu\text{m}$ spot size. Low resolution survey and high resolution region scans at the binding energy of interest were taken for each sample. To minimize charging, samples were flooded with low-energy electrons and ions from the instrument's built-in charge neutralizer. The samples were also sputter cleaned inside the analysis chamber with 1 keV Ar⁺ ions for 30 seconds to remove adventitious contaminants and surface oxides. Data were analyzed using CASA XPS software, and energy corrections on high resolution scans were done by referencing the C1s peak of adventitious carbon to 284.5 eV.

X-ray absorption spectra were collected at the Stanford Synchrotron Radiation Lightsource (SSRL) on beamline 7-3 (Ni K-edge) and 4-3 (S K-edge) at an electron energy of 3.0 GeV with an average current of 500 mA. At beamline 7-3, the radiation was monochromatized by a Si(220) double-crystal monochromator. The intensity of the incident X-ray was monitored by an N₂-filled ion chamber (I₀) in front of the sample. Data were collected as fluorescence excitation spectra with a Ge 30 element detector (Canberra). Energy was calibrated by the first peak maximum of the first derivative of a nickel foil XAS (8333.0 eV). All data were collected at room temperature. The details of EXAFS curve fitting are included in the supporting information. At beamline 4-3, the incoming X-ray was monochromatized by a Si(111) double-crystal monochromator. The intensity of the incident X-ray was monitored by a He-filled ion chamber (I₀) in front of the sample. Data were collected as fluorescence excitation spectra with a Vortex 4 element silicon drift detector (SII NanoTechnology). Monochromator energy was calibrated to the 1st peak of thiosulfate reference sample, which was assigned at 2472.0 eV. The sample environment was kept under He gas atmosphere with He-filled bag to reduce air absorption of incoming X-rays and fluorescence signals. The data were collected at room temperature.

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Notes and references

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TOC

Nickel-sulfide films prepared by facile potentiodynamic deposition are active hydrogen evolution catalysts in aqueous media with a wide range of pH values (0 to 14), as well as in natural water.

